Supporting information

Controlled synthesis of Ni_{0.25}Co_{0.75}(OH)₂ nanoplates and their electrochemical properties

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CTAB concentration (mM)	Average diameter (nm)	Image
10	183.2	8-4800 10 0kV & 7mm x80 0k SE(M) 1 00um
5	171.5	8-4800 10.0kV 8.8mm x50.0k SE(M) 1.00um 6-4800 10.0kV 8.8mm x100k SE(M) 500hm
1	156	S-4800 10 0kV & 8mm x50 0k SE(M) 1 00um
0.5	152.6	3-4600 10 0kV & 9mm xt0 0k SE(M) 1.00um
0.1	115.19	S-4800 10.0kV 9.0mm x50.0k SE(M) 1.00um S-4800 10.0kV 9.0mm x200k SE(M) 200nm

Table S1. The various concentration of the CTAB in synthesis and its corresponding SEM images and average diameters.



Figure S1 Variation of the diameters of the hexagonal nanoplate against the concentration of CTAB.



Figure S2. The pore size distribution of the two kinds of Ni_{0.25}Co_{0.75}(OH)₂ nanoplates.